fteval Journal for Research and Technology Policy Evaluation

INFORMATIONEN FOR AUTHORS

GENERAL DIRECTION

The "fteval Journal for Research and Technology Policy Evaluation" aims to interface practical research and technology policy with academic quality. We intend to alternate journals with a special thematic focus and journals without a special key theme. The journal addresses the following formats:

- Scientific articles (e.g. on methods, analytical research) which relate to the current scientific discourse
- Practice orientated articles (e.g. evaluation resumes, case studies)
- Reviews of books, forums, courses or events
- Commentaries and opinion pieces
- Announcements, short communications, information

The "fteval Journal for Research and Technology Policy evaluation" is open access and it does not charge any fees to authors for contribution or processing.

PAPER SUBMISSION POLICY

Researchers as well as research and technology policy practitioners are welcome to submit their papers to office@fteval.at. We accept papers in German and English. They have to address aspects of the research and technology policy evaluation area. If positively quality assured, the article will be published in the language of submission. Occasionally we offer additional editorial support.

Submissions to "fteval Journal for Research and Technology Policy Evaluation" are not formally peer-reviewed. Instead they are quality assured and screened by the editorial board to ensure that they fit the subject area; do not contravene any of our policies; are of good quality and can reasonably be considered as part of academic literature.

If a submission is found to be unsuitable in any of these aspects then it will not be accepted for publishing. Content which is considered to be fake, non-scientific or pseudoscientific will not pass our screening. The screening also includes mending of obvious typos. It may include a recommendation for publication respectively modification. The screening shall not last longer than four weeks.



The managing director of the Platform fteval finally decides whether or not a paper will be published based on the recommendations of the editorial board members in charge of screening the submitted paper. If required he may request additional feedback of the board of the Platform fteval.

In order to maintain the integrity of the scientific literature, authors should not post material which has been previously published in, or which has been accepted for publication by, a formal peer-reviewed journal. The "fteval Journal for Research and Technology Policy Evaluation" does, however, not insist on exclusive publishing rights, thus authors can also try to republish their articles in other professional journals. However, authors should make their own enquiries how other publishers treat this issue if they wish to submit a paper already published in the "fteval Journal for Research and Technology Policy Evaluation" to another journal. If published in another journal, we ask to mention in a footnote or in an acknowledgement that the article was firstly published in the "fteval Journal for Research and Technology Policy Evaluation".

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LAYOUT

- In case of praxis-oriented contributions the article should contain between 4-10 pages of full text (1 page of full-text contains about 3000 signs including blanks)
- In case of academic contributions the article should contain between 6-15 pages of full text (1 page of full-text contains about 3000 signs including blanks)
- Please mail the article as MS-Winword
- Graphics please in grey shades
- Please send us graphics also separately as image file in high definition (300dpi)
- Footnotes at bottom of page
- References at the end of the article
- information about the author (institution, address, e-mail)

For questions please contact:

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THANK YOU VERY MUCH FOR YOUR CONTRIBUTION!

